T 37		Louis de la company de la comp	I DD	m:
L Number	Hits		DB USPAT;	Time stamp
1	2	jp-2000035665-\$.did.	US-PGPUB;	2003/07/09 08:57
			EPO; JPO;	
			DERWENT	
_	2	(("20020068237") or ("20020068236")).PN.	US-PGPUB	2003/07/09 08:57
	1975440		USPAT;	2003/07/07 12:06
	13,3110	robin robio photorior	US-PGPUB;	2000,01,07
			EPO; JPO;	į
			DERWENT	ļ
-	16077	(photoacid acid) near generat\$3	USPAT;	2003/07/07 12:06
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	78586	photosensitizer sensitizer	USPAT;	2003/07/07 12:05
			US-PGPUB;	
		1 C 1	EPO; JPO;	
		1 ast search	DERWENT	
-	1008314	solvent Lost Control	USPAT;	2003/07/03 13:46
		solvent East Search	US-PGPUB;	
		1	EPO; JPO;	
			DERWENT	
-	1234		USPAT;	2003/07/03 13:49
		acid) near generat\$3) and (photosensitizer	US-PGPUB;	
		sensitizer ) and solvent	EPO; JPO;	
			DERWENT	( (
-	5890	benzopyran	USPAT;	2003/07/07 12:06
			US-PGPUB;	
			EPO; JPO; DERWENT	
_	25	((resin resist photoresist) and ((photoacid	USPAT;	2003/07/07 11:40
-	23	acid) near generat\$3) and (photosensitizer	US-PGPUB;	2003/07/07 11.40
		sensitizer ) and solvent) and benzopyran	EPO; JPO;	
		Sensitizer / and solvene, and sensopyran	DERWENT	
- '	155	imai-g imai-genichi imai-genji	USPAT;	2003/07/08 16:22
	133		US-PGPUB;	2003,0,,00 10.22
			EPO; JPO;	
			DERWENT	
-	6	(IMAI-G IMAI-GENICHI IMAI-GENJI) and	USPAT;	2003/07/07 12:01
		benzopyran	US-PGPUB;	
		/	EPO; JPO;	
		<b>1</b>	DERWENT	
-	78586	photosensitizer sensitizer	USPAT;	2003/07/07 12:06
		A list War was	US-PGPUB;	
		N D RVIII (KPAMOVY )	EPO; JPO;	
			DERWENT	0000/05/05 50 55
<sup>-</sup>	5890	benzopyran	USPAT;	2003/07/07 12:06
			US-PGPUB;	
			EPO; JPO; DERWENT	
_	61	(photosensitizer sensitizer ) same	USPAT;	2003/07/07 12:08
	01	benzopyran	US-PGPUB;	2003,01,01 12.00
		20.120212011	EPO; JPO;	
			DERWENT	
-	16077	(photoacid acid) near generat\$3	USPAT;	2003/07/07 17:04
	,		US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	1975440	resin resist photoresist	USPAT;	2003/07/07 12:06
			US-PGPUB;	'
			EPO; JPO;	
			DERWENT	
-	7	((photosensitizer sensitizer ) same	USPAT;	2003/07/07 12:07
		benzopyran ) and ((photoacid acid) near	US-PGPUB;	
		generat\$3 ) and (resin resist photoresist )	EPO; JPO;	
			DERWENT	
-	3	(((photosensitizer sensitizer ) same	USPAT;	2003/07/07 12:07
		benzopyran ) and ((photoacid acid) near	US-PGPUB;	
		generat\$3 ) and (resin resist photoresist ))	EPO; JPO;	
		not ((IMAI-G IMAI-GENICHI IMAI-GENJI) and	DERWENT	
Ll		benzopyran)	L	L

-	20	((photosensitizer sensitizer ) same benzopyran ) and (resin resist photoresist )	USPAT; US-PGPUB; EPO; JPO;	2003/07/07 12:08
-	13	(((photosensitizer sensitizer ) same benzopyran ) and (resin resist photoresist )) not (((IMAI-G IMAI-GENICHI IMAI-GENJI)	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/07/07 12:10
		<pre>and benzopyran) (((photosensitizer sensitizer ) same benzopyran ) and ((photoacid acid) near generat\$3 ) and (resin resist photoresist )))</pre>	DERWENT	
-	0	jp-8334897-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 12:10
-	2	jp-08334897-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 12:26
-	2	jp-11212252-\$.did. or jp-2000275823 or jp-2000056450	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 12:27
	6	(jp-11212252-\$.did. or jp-2000275823 or jp-2000056450) jp-09138502-\$.did. jp-2000035665-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 12:27
-	2	jp-2000035665-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 12:49
-	2	titanocene same (\$5acid near generator)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 13:47
-	1	(titanocene adj compound) same (\$5acid near generator)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 13:47
-	0	((titanocene adj compound) same (\$5acid near generator)) not (titanocene same (\$5acid near generator))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 13:48
-	51	<pre>(radical adj generator) same ((acid photoacid) near generator)</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:24
-	900	<pre>(resin resist photoresist binder) and ((photoacid acid) near generator) and (photosensitizer sensitizer)</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 17:03
	509	((resin resist photoresist binder) and ((photoacid acid) near generator) and (photosensitizer sensitizer)) and negative	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:26
-	3797882	photocurable curable cur\$5 negative crosslinkable crosslinked crosslink (cross adj link\$4) cross-link\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:27
-	509	(((resin resist photoresist binder) and ((photoacid acid) near generator) and (photosensitizer sensitizer)) and negative) and (photocurable curable cur\$5 negative crosslinkable crosslink (cross	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:28
-	4167371	adj link\$4) cross-link\$4) dry drying heat-treat\$5 (heat\$5) bak\$4 pre-bake\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:30

-	4553605	coat coating apply applying applied coated spin-coated spin-coat (spin adj (coated coat coating))	USPAT; US-PGPUB; EPO; JPO;	2003/07/07 14:31
-	1655136	irradiate irradiating expose exposure exposing exposed irradiated irradiation	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/07/07 14:31
-	1640490	develop development developing developed ]	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/07/07 14:32
-	360309	(visible adj light) "VIS"	DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:32
-	57817	(dry drying heat-treat\$5 (heat\$5) bak\$4 pre-bake\$4) and (coat coating apply applying applied coated spin-coated spin-coat (spin adj (coated coat coating))) and (irradiate irradiating expose exposure exposing exposed irradiated irradiation) and (develop development developing developed]) and ((visible adj light) "VIS")	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:33
-	208	(((resin resist photoresist binder) and ((photoacid acid) near generator) and ((photosensitizer sensitizer)) and negative) and ((dry drying heat-treat\$5 (heat\$5) bak\$4 pre-bake\$4) and (coat coating apply applying applied coated spin-coated spin-coat (spin adj (coated coat coating))) and (irradiate irradiating expose exposure exposing exposed irradiated irradiation) and (develop development developing developed]) and ((visible adj light) "VIS"))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:37
	50	((VISIBLE add Tight) "VIS")) ((((resin resist photoresist binder) and ((photoacid acid) near generator) and (photosensitizer sensitizer)) and negative) and ((dry drying heat-treat\$5 (heat\$5) bak\$4 pre-bake\$4) and (coat coating apply applying applied coated spin-coated spin-coat (spin adj (coated coat coating))) and (irradiate irradiating expose exposure exposing exposed irradiated irradiation) and (develop development developing developed ]) and ((visible adj light) "VIS"))) and (peel peeling peelable peeled (peel\$4-apart) (peel\$4 near apart))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 14:41
-	27	((((resin resist photoresist binder) and ((photoacid acid) near generator) and (photosensitizer sensitizer)) and negative) and ((dry drying heat-treat\$5 (heat\$5) bak\$4 pre-bake\$4) and (coat coating apply applying applied coated spin-coated spin-coat (spin adj (coated coat coating))) and (irradiate irradiating expose exposure exposing exposed irradiated irradiation) and (develop development developing developed ]) and ((visible adj light) "VIS"))) and (peel peeling peelable peeled (peel\$4-apart) (peel\$4 near apart))	USPAT; EPO; JPO; DERWENT	2003/07/07 15:48
-	2	("6033826").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 15:48
-	1	(("6033826").PN.) and (generator) and (\$5sensitizer)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/07 16:31

	<del>,</del>			
-	32	pyrene same (benzopyran)	USPAT;	2003/07/07 15:54
	ţ		US-PGPUB; EPO; JPO;	
	]		DERWENT	
_	18	(((((resin resist photoresist binder) and	USPAT;	2003/07/07 17:03
		((photoacid acid) near generator) and	US-PGPUB;	, , ,
		(photosensitizer sensitizer)) and negative)	EPO; JPO;	
		and ((dry drying heat-treat\$5 (heat\$5) bak\$4	DERWENT	
		pre-bake\$4) and (coat coating apply applying		
		applied coated spin-coated spin-coat (spin		
		adj (coated coat coating))) and (irradiate		
		irradiating expose exposure exposing exposed irradiated irradiation ) and (develop		
	1	development developing developed ]) and		
	1	((visible adj light) "VIS"))) and (peel		
		peeling peelable peeled (peel\$4-apart)		
		(peel\$4 near apart) ) ) and ((visible VIS)		
		near light)		
-	0	(((((resin resist photoresist binder) and	USPAT;	2003/07/07 17:02
		((photoacid acid) near generator) and	US-PGPUB;	
		(photosensitizer sensitizer)) and negative) and ((dry drying heat-treat\$5 (heat\$5) bak\$4	EPO; JPO; DERWENT	
		pre-bake\$4) and (coat coating apply applying	DEKMENI	
		applied coated spin-coated spin-coat (spin		
		adj (coated coat coating))) and (irradiate		
		irradiating expose exposure exposing exposed		
		irradiated irradiation ) and (develop		
		development developing developed ]) and		
		((visible adj light) "VIS"))) and (peel		
		peeling peelable peeled (peel\$4-apart)		
		(peel\$4 near apart) ) ) and ((visible VIS) near light)) and benzopyran		
_	0	(((((resin resist photoresist binder) and	USPAT;	2003/07/07 17:02
	, .	((photoacid acid) near generator) and	US-PGPUB;	2003,07,07 17.02
		(photosensitizer sensitizer)) and negative)	EPO; JPO;	
		and ((dry drying heat-treat\$5 (heat\$5) bak\$4	DERWENT	
		pre-bake\$4) and (coat coating apply applying		
		applied coated spin-coated spin-coat (spin	,	
		adj (coated coat coating))) and (irradiate		
		irradiating expose exposure exposing exposed irradiated irradiation ) and (develop		
		development developing developed ]) and		
		((visible adj light) "VIS"))) and (peel		
		peeling peelable peeled (peel\$4-apart)		
1		(peel\$4 near apart) ) ) and benzopyran		
-	2248	((visible adj light) "VIS") and benzopyran	USPAT;	2003/07/07 17:02
			US-PGPUB;	
]			EPO; JPO; DERWENT	
_	395	(((visible adj light) "VIS") and benzopyran)	USPAT;	2003/07/07 17:03
	]	and ((visible VIS) near light)	US-PGPUB;	2003/01/01 17:03
			EPO; JPO;	
			DERWENT	
-	293	(resin resist photoresist binder) and	USPAT;	2003/07/07 17:03
]		((((visible adj light) "VIS") and	US-PGPUB;	
		benzopyran) and ((visible VIS) near light))	EPO; JPO;	
		(Inhahanaid anid) mass same (A2 ) and	DERWENT	2002/05/25 15 15
-	21	((photoacid acid) near generat\$3 ) and	USPAT;	2003/07/07 17:45
		<pre>((resin resist photoresist binder) and ((((visible adj light) "VIS") and</pre>	US-PGPUB; EPO; JPO;	
		benzopyran) and ((visible VIS) near light)))	DERWENT	
-	1	ls-148	USPAT;	2003/07/07 18:04
] .	_		US-PGPUB;	
			EPO; JPO;	
[ i			DERWENT	
-	2	JP-11258798-\$.DID.	USPAT;	2003/07/07 18:04
			US-PGPUB;	
			EPO; JPO; DERWENT	
L			DEKMENI	L

-	2	benzopyran adj condensed adj ring	USPAT;	2003/07/08 11:34
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
	7521	condensed adj ring	USPAT;	2003/07/08 11:53
1	/521	Condensed adj 11ng	1	2003/07/08 11:53
			US-PGPUB;	1
			EPO; JPO;	
	_		DERWENT	
-	72	proliferating adj agent	USPAT;	2003/07/08 13:48
İ			US-PGPUB;	
			EPO; JPO;	1
			DERWENT	
-	2661	sodium adj lamp	USPAT;	2003/07/08 12:09
			US-PGPUB;	
ì			EPO; JPO;	
			DERWENT	
-	120	(sodium adj lamp) same (nm wavlength)	USPAT;	2003/07/08 12:10
		(555222 42) 24p, 545 (1 114.251.351.)	US-PGPUB;	2000, 00, 00 22,120
			EPO; JPO;	
			DERWENT	
	72	neoliforating add agent		2003/07/08 14:31
1	72	proliferating adj agent	USPAT;	2003/07/00 14:31
			US-PGPUB;	
	[		EPO; JPO;	
			DERWENT	/
-	2	jp-09138502-\$.did.	USPAT;	2003/07/08 13:50
· ·	1		US-PGPUB;	
	1		EPO; JPO;	
	1		DERWENT	
-	2	("6140025").PN.	USPAT;	2003/07/08 14:06
			US-PGPUB;	
			EPO; JPO;	1
			DERWENT	
_	12	(proliferating adj agent ) and (resin resist	USPAT;	2003/07/08 14:09
	12	photoresist)	US-PGPUB;	2003/07/00 14:03
		photoresist	EPO; JPO;	1
		(	DERWENT	0000/05/00 5/ 05
-	0	(proliferating adj agent) same ((fluidity	USPAT;	2003/07/08 14:35
		adj adjuster) (adhesion adj improver)	US-PGPUB;	
		(cissing adj inhibitor) (polymerization adj	EPO; JPO;	l i
		inhibitor) pigment plasticizer)	DERWENT	1
-	134		USPAT;	2003/07/08 14:58
		adj adjuster) (adhesion adj improver)	US-PGPUB;	İ
i	ŀ	(cissing adj inhibitor) (polymerization adj	EPO; JPO;	
		inhibitor) pigment plasticizer)	DERWENT	
-	83	l	USPAT;	2003/07/08 14:58
		((fluidity adj adjuster) (adhesion adj	US-PGPUB;	
		improver) (cissing adj inhibitor)	EPO; JPO;	
		(polymerization adj inhibitor) pigment	DERWENT	
		plasticizer)) and (resist photoresist resin)		
_	79	((organic adj acid adj ester) same	USPAT;	2003/07/08 14:46
	'3	((fluidity adj adjuster) (adhesion adj	EPO; JPO;	-005, 57, 55 14.46
	-	improver) (cissing adj inhibitor)	DERWENT	
		(polymerization adj inhibitor) pigment	DEKWENT	
	1 2542	plasticizer)) and (resist photoresist resin)	HODAM	2003/07/00 34 50
-	2648	(organic adj acid adj ester)	USPAT;	2003/07/08 14:58
			US-PGPUB;	
			EPO; JPO;	
		[,, , , ,, ,, ,, ,, ,, ,, ,, ,, ,, ,, ,,	DERWENT	
-	1070	((organic adj acid adj ester) ) and (resist	USPAT;	2003/07/08 14:59
		photoresist resin)	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	834	((organic adj acid adj ester) ) and (resist	USPAT	2003/07/08 15:13
		photoresist resin)		
-	0	430.270.1.ccls.	USPAT	2003/07/08 15:00
-	2718		USPAT	2003/07/08 15:09
_	-1.23	430/270.1.ccls. and (((organic adj acid adj	USPAT	2003/07/08 15:01
		ester) ) and (resist photoresist resin))		
_	6	l	USPAT	2003/07/08 15:08
		ester) )	331.11	-005, 07, 00 13.00
L	1	Cater/ /	L	I

_	1	(430/270.1.ccls. and ((organic adj acid adj	USPAT	2003/07/08 15:08
		ester) )) not (430/270.1.ccls. and		
		(((organic adj acid adj ester) ) and (resist		
		photoresist resin)))		
-	112	430/\$.ccls. and ((organic adj acid adj	USPAT	2003/07/08 15:11
		ester) )		
-	5270	430/\$.ccls. and (organic adj acid)	USPAT	2003/07/08 15:12
-	280	430/270.1.ccls. and (organic adj acid)	USPAT	2003/07/08 15:12
-	269	(430/270.1.ccls. and (organic adj acid)) and	USPAT	2003/07/08 15:23
	}	(resist photoresist resin)		
-	89	((430/270.1.ccls. and (organic adj acid))	USPAT	2003/07/08 15:30
		and (resist photoresist resin)) and (visible		
		near light)		1
-	44	(((430/270.1.ccls. and (organic adj acid))	USPAT	2003/07/08 16:20
		and (resist photoresist resin)) and (visible		
		near light)) and negative		
-	97	principal ( (principal transfer )	USPAT	2003/07/08 16:21
		generator) and (photosensitizer sensitizer)		
		and (visible near light)		
-	155	IMAI-G IMAI-GENICHI IMAI-GENJI	USPAT;	2003/07/08 16:22
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	2	(F	USPAT;	2003/07/08 16:33
		generator) and (photosensitizer sensitizer)	US-PGPUB;	
		and (visible near light)) and (IMAI-G	EPO; JPO;	
		IMAI-GENICHI IMAI-GENJI )	DERWENT	
-	2	("5801212").PN.	USPAT;	2003/07/08 16:33
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	